

**Chemical bath deposition of SnS thin films from the solutions with different concentrations of tin and sulphur**  
**Safonova, Maria; Mellikov, Enn; Mikli, Valdek; Kerm, Karin; Naidu, Revathi; Volobujeva, Olga** Inter Academia 2014 - Global Research and Education 2015 / p. 183-186 : ill <http://dx.doi.org/10.4028/www.scientific.net/AMR.1117.183>

**Impact of vacuum and nitrogen annealing on HVE SnS photoabsorber films**  
**Revathi, Naidu; Looirts, Mihkel; Kärber, Erki; Volobujeva, Olga; Raudoja, Jaan; Maticiuc, Natalia; Bereznev, Sergei; Mellikov, Enn** Materials science in semiconductor processing 2017 / p. 252-257 : ill <https://doi.org/10.1016/j.mssp.2017.08.004> [Journal metrics at Scopus](#) [Article at Scopus](#) [Journal metrics at WOS](#) [Article at WOS](#)

**Thermal annealing of sequentially deposited SnS thin films**  
**Safonova, Maria; Nair, Padmanabhan Pankajakshy Karunakaran; Mellikov, Enn; Aragon, Rebeca; Kerm, Karin; Naidu, Revathi; Mikli, Valdek; Volobujeva, Olga** Proceedings of the Estonian Academy of Sciences 2015 / p. 488-494 : ill <https://doi.org/10.3176/proc.2015.4.04> [Journal metrics at Scopus](#) [Article at Scopus](#) [Journal metrics at WOS](#) [Article at WOS](#)

**Tin sulfide films by spray pyrolysis technique using L-cysteine as a novel sulfur source**  
**Polivtseva, Svetlana; Oja Acik, Ilona; Katerski, Atanas; Mere, Arvo; Mikli, Valdek; Krunks, Malle** Physica status solidi (c) 2016 / p. 18-23 : ill <https://doi.org/10.1002/pssc.201510098> [Journal metrics at Scopus](#) [Article at Scopus](#) [Article at WOS](#)